FORM 1449* INFORMATION DISCLOSURE STATEMENT	Docket Number:		
IN AN APPLICATION	Applicant: Yukio Nishimura et al.		
(Use several sheets if necessary)	Filing Date: April 29, 2005	Group Art Unit:	

			U	S. PATENT DOCUMENTS				·	
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		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRAN	ANSLATION	
		NO.					YES	NO	
/ACV	VAA	JP59045439	03-14-1984	Japan (w/Eng. Abstract)				х	
/ACW/	AB	JP04226461	08-17-1992	Japan (w/Eng. Abstract)			•	X	
/ACW/	AC	JP07234511	09-05-1995	Japan (w/Eng. Abstract)				х	
/ACW/	AD	JP2002-072484	09-05-1995	Japan (w/Eng. Abstract)				x	
		OTHER	DOCUMENT	S (Including Author, Title, Da	te, Pertinent Pag	es, Etc.)			
/ACW/	AE	INTERNATION	AL SEARCH R	EPORT for International Appl	ication No. PCT	/JP03/13560 dated	17 Februar	у, 2004	

				
EXAMINER	/Amanda C. Walke/	DATE CONSIDERED	08/13/2007	

	FORM 1449* INFORMATION DISCLOSURE STATEMENT	Docket Number: 70020-0061USWO	Application Number: 10/533,223	
	IN AN APPLICATION	Applicant: Yukio Nishimura et al.		
l	(Use several sheets if necessary)	Filing Date: April 29, 2005	Group Art Unit:	

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		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRAN	SLATION
	:		:				YES	NO
/ACW	AF	JP2001-188347	07-10-2001	Japan (w/Eng. Abstract)				X.
/ACW/	AG	EP1048983 A1	11-02-2000	Europe	•		х	
/ACW/	АН	JP2002-169287	06-14-2002	Japan (w/Eng. Abstract)				х
/ACW/	Al	JP2002-162745	06-07-2002	Japan (w/Eng. Abstract)				х
		OTHER	DOCUMENT	S (Including Author, Title, Da	ite, Pertinent Pag	es, Etc.)	*	
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FORM 1449* INFORMATION DISCLOSURE STATEMENT	Docket Number: 70020-0061 USWO	Application Number: 10/533,223	
IN AN APPLICATION ·	Applicant: Yukio Nishimura et al.		
(Use several sheets if necessary)	Filing Date: April 29, 2005	Group Art Unit:	

			U.	S. PATENT DOCUMENTS				<u> </u>
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		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRAN	SLATION
:		NO.					YES	NO
/AC\	(A)	JP2002-303979	03-14-1984	Japan (w/Eng. Abstract)				х
	AK	JP2002-182393	06-26-2002	Japan (w/Eng. Abstract)				х
/ACW/	AL	EP1319981A2	06-18-2003	Europe			·x	
/ACW/	AM	JP2003-140349	05-14-2003	Japan (w/Eng. Abstract)				х
IACVVI	<u> </u>		DOCUMENT	S (Including Author, Title, Da	te, Pertinent Pag	es, Etc.)		
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EXAMINER	/Amanda C. Walke/	DATE CONSIDERED	08/13/2007

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		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRAN	SLATION
							YES	NO
۱A /\/	AN J	JP2003-345022	12-03-2003	Japan (w/Eng. Abstract)				X
// A0	AO J	JP2003-337419	11-28-2003	Japan (w/Eng. Abstract)				X
		OTHER	DOCUMENT	S (Including Author, Title, Da	te, Pertinent Pag	es, Etc.)		
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		OTHER	DOCUMENT	S (Including Author, Title, Da				

			
EXAMINER	/Amanda C. Walke/	DATE CONSIDERED	08/13/2007

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

FORMATION DISCLOSURE STATEMENT (PTO 1449)

ATTORNEY DOCKET NO. 70020.0061USW	10
u.s. application serial no. 10/533,223	CONFIRMATION NO
FILING DATE April 27, 2006	

INVENTOR(S)

Yukio NISHIMURA et al.

EXAMINER

Not Assigned

GROUP ART UNIT

TITLE OF APPLICATION

RADIATION-SENSITIVE RESIN COMPOSITION

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENT DOCUMENTS							
TRANSLATION						TRANSLATION	

		DOCUMENT NO.	DATE	DATE COUNTRY	CLASS	SUBCLASS	TRANSLATION	
		DOCUMENT NO.	DATE				YES	NC
/ACW	В	JP-2003-241386	8/27/03	Japan			Abstract and English Translation	
/ACW/	С	JP-2004-046098	2/12/04	Japan			Abstract	

		OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)
/ACW	/D	Japanese Official Action - Notice of Final Rejection for Japanese Patent Application No. 2003-359842 dated August 14, 2006 - 3 pages, English translation 6 pages.
/AC	₩/	Japanese Official Action - Notice of Reasons for Rejections for Japanese Patent Application No. 2003-359842 dated August 14, 2006 - 3 pages, English translation 6 pages.

EXAMINER	DATE CONSIDERED					
/Amanda C. Walke/	11/20/2007					
EXAMINER: Initial if the reference is considered, whether or not the citation is in conformance with MPEP 609. Draw a line through the citation if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.						